



Solid • Smart • Stable

COAT ■ DEVELOP ■ BAKE ■ WEE

A leading supplier of  
photoresist process and  
cleaning equipment

### Smart tools that maximize performance and lower cost of ownership

S-Cubed provides higher reliability, more functionality and a smaller footprint - all at a lower cost. We do this by eliminating “non value added” hardware and by the use of advanced controls, software and robotics.

#### Applications

- Patterned Sapphire Substrates (PSS)
- BEOL
- MEMS
- LED/OLED
- III - V Telecom Materials
- PV Photo Voltaics
- Mask Cleaner



#### S-Cubed System Features

- Small footprint
- Color LCD touchscreen
- One or two spin modules
- Unlimited process storage capabilities
- Remote data collection and control
- Stacked thermal modules
- Multiple size substrates without change
- Servo motion control
- Process substrates up to 300 mm
- Proven modular design
- Ultra high reliability

For more information on all products including the new Flexi III™ system, the TruClean™ double sided scrubbing systems, and Cyclone™ spin processors, please visit our website: [www.s-cubed.com](http://www.s-cubed.com).



## FLEXI™

### Photoresist Processing Systems

Capable of processes including: Prime, Chill, Coat, Bake, PEB, WEE, Develop - with up to 50 wafers on the tool this work horse can do it all.



## FLEXI BASIC™

### Photoresist Processing Systems

Built on the Flexi III chassis this tool minimizes cost by substituting pneumatic process actuation for servo process actuation, while offering adjustable rather than fully programmable functionality.



## FORCE 300™

Utilizing a double end effector high speed robot the Force 300 offers the highest productivity for 300mm wafer processing. The tool is capable of system expansion with multiple robots and modules.



## CYCLONE™

Ideal for cleaning after dicing operations or for mask cleaning.



## WEE™

### Double Sided Scrub System

PVA and/or nylon brushes for double and single sided wafer or substrate scrubbing. Manual or fully automated cassette to cassette.



## PRC 6625™

### Back Side Reticle Cleaner

The PRC 6625 (patent pending) provides a means of cleaning the back side of a Pelliculized Reticle without affecting nor even touching the Pelliculized side of the reticle.